

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.

[illegible]

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.¹	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages Or Relevant Figures Appear	T^e
		Country Code³-Number⁴-Kind Code⁵ (<i>if known</i>)	MM-DD-YYYY			

Examiner Signature		Date Considered	
-----------------------	--	--------------------	--

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and (*) not considered. Include copy of this form with next communication to applicant. * CITE NO.: Those application(s) which are marked with an single asterisk (*) next to the Cite No. are not supplied (under 37 CFR 1.98(a)(2)(iii)) because that application was filed after June 30, 2003 or is available in the IFW. ¹ Applicant's unique citation designation number (optional). ² See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number.

Substitute for form 1449/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(Use as many sheets as necessary)</i>			Complete if Known		
			Application Number	10/756,122-Conf. #4554	
			Filing Date	January 13, 2004	
			First Named Inventor	Wai-Fan Yau	
			Art Unit	2823	
			Examiner Name	J. J. Maldonado	
Sheet	2	of	2	Attorney Docket Number	002592.C7/DSM/LOW K/JW

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
	C1	K.H.A. BOGART, ET AL., "Plasma Enhanced Chemical Vapor Deposition of SiO ₂ Using Novel Alkoxysilane Precursors," J. Vac. Sci. Technol. A, Vol. 13, No. 2, Mar/Apr 1995, pages 475-480.	
	C2	A. KLUMP, "Photo Induced Transformation of Polysiloxane Layers to SiO ₂ ," Applied Surface Science, Volume 43 (1989), pages 301-303.	
	C3	The Board's Decision on Appeal mailed September 16, 2004, for Serial No. 09/477,126, filed December 30, 1999 (AMAT/2592.X1).	
	C4	The Board's Decision on Request for Rehearing mailed December 23, 2004, for Serial No. 09/477,126, filed December 30, 1999 (AMAT/2592.X1).	
	C5	WOLF, et al.; Silicon Processing for the VLSI Era, Volume 1; Process Technology, 1986 by Lattice Press, pp. 161-174.	
	C6	Prosecution History for U.S. Patent Application No. 11/877,483 filed October 23, 2007 (APPM/002592.C12)	

Examiner Signature		Date Considered	
-----------------------	--	--------------------	--

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²Applicant is to place a check mark here if English language Translation is attached.